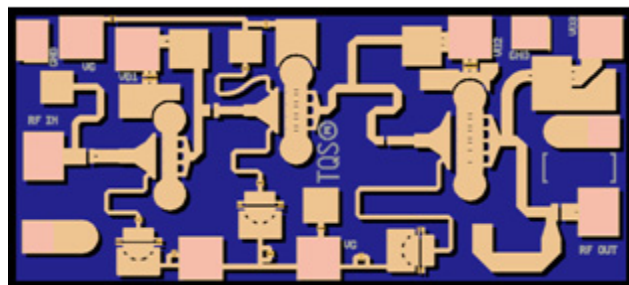


## 32 – 45 GHz Wide Band Driver Amplifier

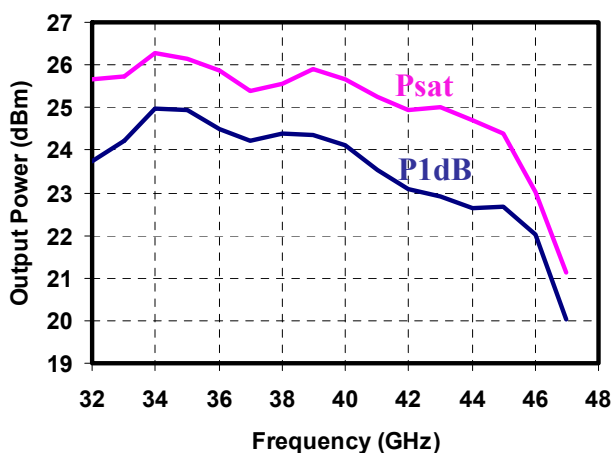
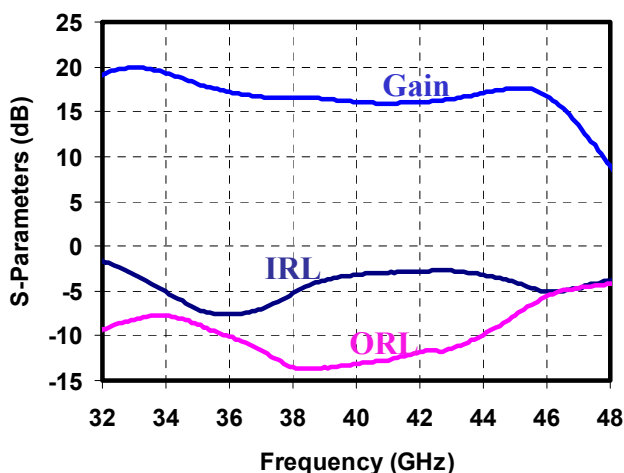


### Key Features

- Frequency Range: 32 - 45 GHz
- 25 dBm Nominal Psat @ 38 GHz
- 24 dBm P1dB @ 38 GHz
- 16 dB Nominal Gain @ 38 GHz
- 33 dBm OTOI @ 16dBm/Tone
- Bias: 6 V @ 175 mA Idq
- 0.15  $\mu$ m 3MI pHEMT Technology
- Chip Dimensions 1.60 x 0.75 x 0.10 mm  
(0.063 x 0.030 x 0.004 in)

### Measured Fixtured Data

Bias Conditions:  $V_d = 6$  V,  $I_{dq} = 175$  mA



### Primary Applications

- Digital Radio
- Point-to-Point Radio
- Point-to-Multipoint Communications
- Military SAT-COM

### Product Description

The TriQuint TGA4521 is a compact Driver Amplifier MMIC for Ka-band and Q-band applications. The part is designed using TriQuint's 0.15 $\mu$ m power pHEMT production process.

The TGA4521 nominally provides 25 dBm saturated output power, and 24 dBm output power at 1dB Gain compression @ 38 GHz. It also has typical gain of 16 dB.

The part is ideally suited for low cost emerging markets such as Digital Radio, Point-to-Point Radio and Point-to-Multi Point Communications.

The TGA4521 is 100% DC and RF tested on-wafer to ensure performance compliance.

Lead-Free & RoHS compliant.

Evaluation boards are available upon request.

**TABLE I**  
**MAXIMUM RATINGS 1/**

SYMBOL	PARAMETER	VALUE	NOTES
V <sub>d</sub>	Drain Voltage	6.5 V	<u>2/</u>
V <sub>g</sub>	Gate Voltage Range	-2 TO 0 V	
I <sub>d</sub>	Drain Current	350 mA	<u>2/</u> <u>3/</u>
I <sub>g</sub>	Gate Current	9 mA	<u>3/</u>
P <sub>IN</sub>	Input Continuous Wave Power	20 dBm	
P <sub>D</sub>	Power Dissipation	See note <u>4/</u>	<u>2/</u>
T <sub>CH</sub>	Operating Channel Temperature	150 °C	<u>5/</u> <u>6/</u>
T <sub>M</sub>	Mounting Temperature (30 Seconds)	320 °C	
T <sub>STG</sub>	Storage Temperature	-65 to 150 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P<sub>D</sub>
- 3/ Total current for the entire MMIC.
- 4/ For a median life time of 1E+6 hrs, Power dissipation is limited to:
- $$P_D(\text{max}) = (150\text{ }^{\circ}\text{C} - T_{\text{BASE}}\text{ }^{\circ}\text{C}) / 70\text{ (}^{\circ}\text{C/W)}$$
- Where T<sub>BASE</sub> is the base plate temperature.
- 5/ Junction operating temperature will directly affect the device median time to failure (MTTF). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 6/ These ratings apply to each individual FET.

**TABLE II**  
**ELECTRICAL CHARACTERISTICS**  
(Ta = 25 °C Nominal)

PARAMETER	FREQUENCY (GHz)	MIN	TYPICAL	UNITS
Frequency Range			32 - 45	GHz
Drain Voltage, Vd			6.0	V
Drain Current, Id			175	mA
Gate Voltage, Vg			-0.7	V
Small Signal Gain, S21	32	14.5	20	dB
	36 - 38	15.5	17	
	44	14	17	
Input Return Loss, S11	32	1	1.5	dB
	36	3.5	8	
	38	2.5	5	
	44	2	3	
Output Return Loss, S22	32 - 38	8	10	dB
	44	4	10	
Output Power @ 1dB Gain Compression, P1dB	38	24	24.5	dBm
	32 - 45		23.5	
Saturated Power, Psat			25	dBm
OTOI @ Pin = 1dBm	38	31	33	dBm
	32 - 45		33	

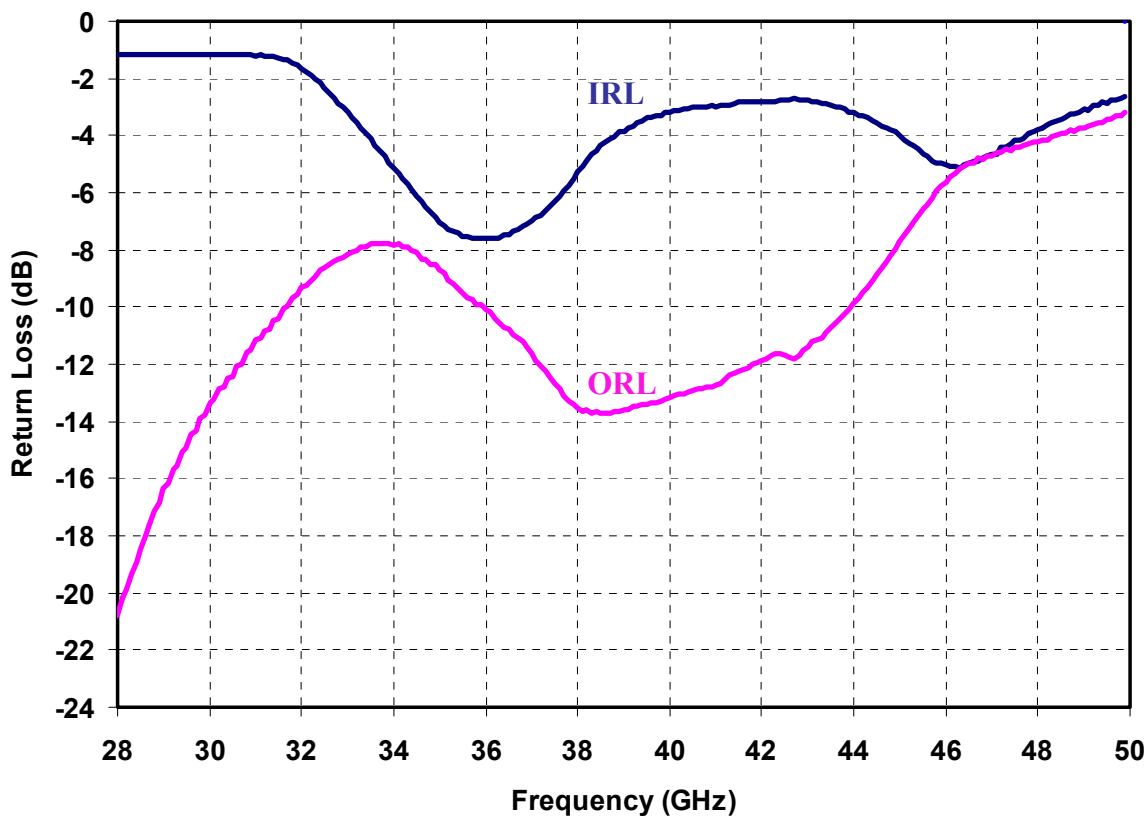
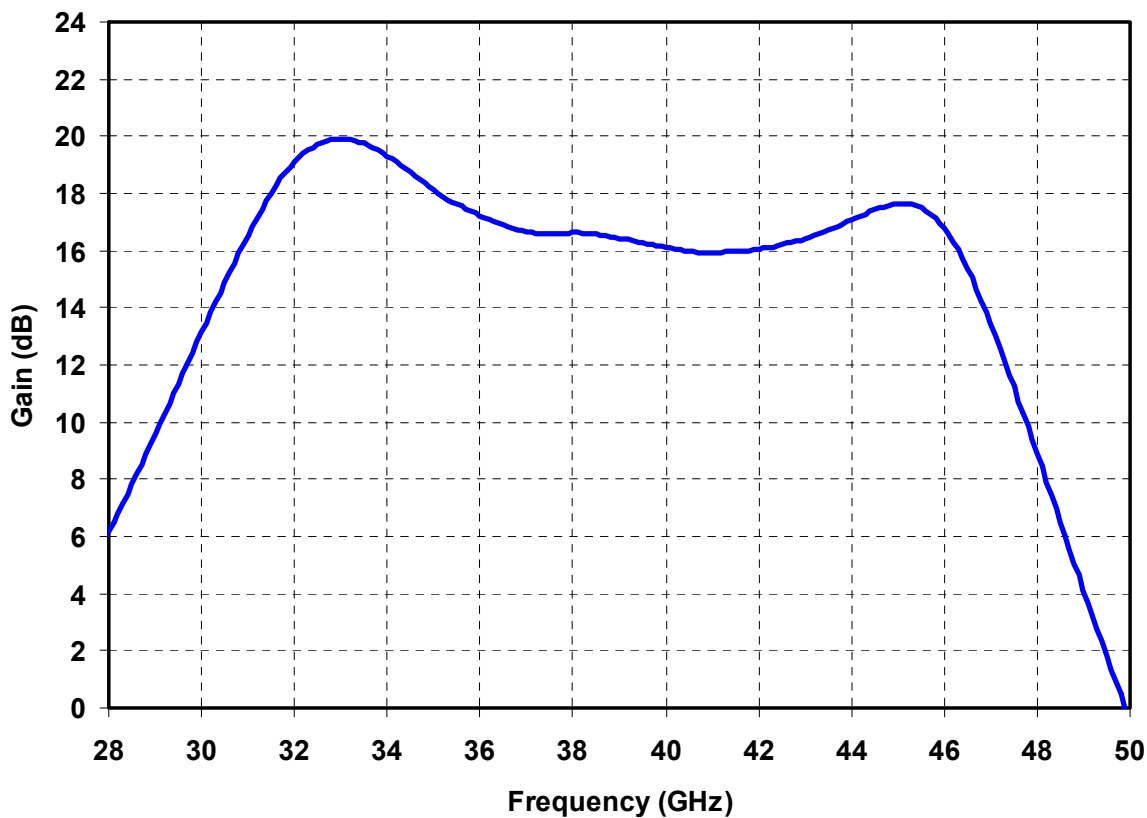
**TABLE III**  
**THERMAL INFORMATION**

PARAMETER	TEST CONDITIONS	T <sub>CH</sub> (°C)	R <sub>θJC</sub> (°C/W)	T <sub>M</sub> (HRS)
R <sub>θJC</sub> Thermal Resistance (channel to Case)	Vd = 6 V Id = 175 mA Pdiss = 1.05 W	144	70	2.0E+6

Note: Assumes eutectic attach using 1.5 mil 80/20 AuSn mounted to a 20 mil CuMo Carrier at 70 °C baseplate temperature. Worst case condition with no RF applied, 100% of DC power is dissipated.

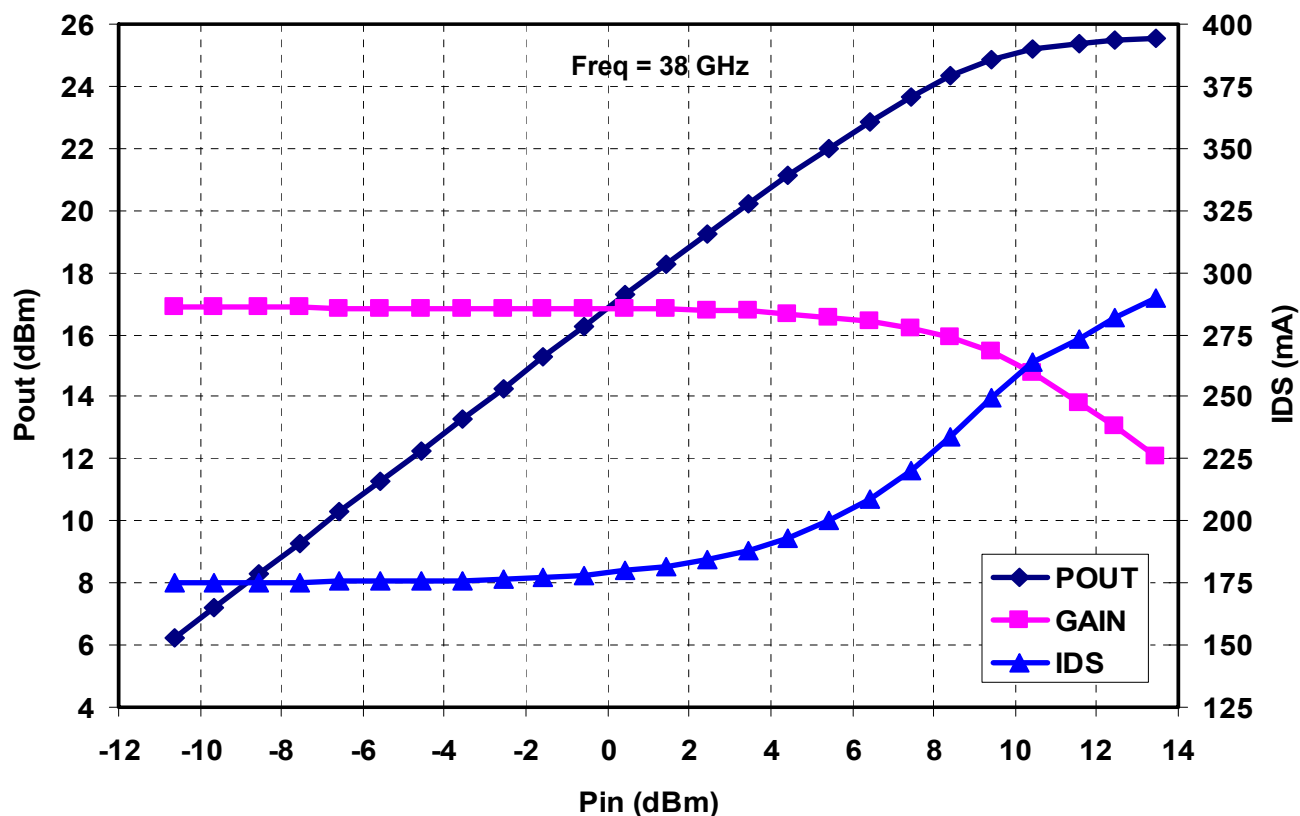
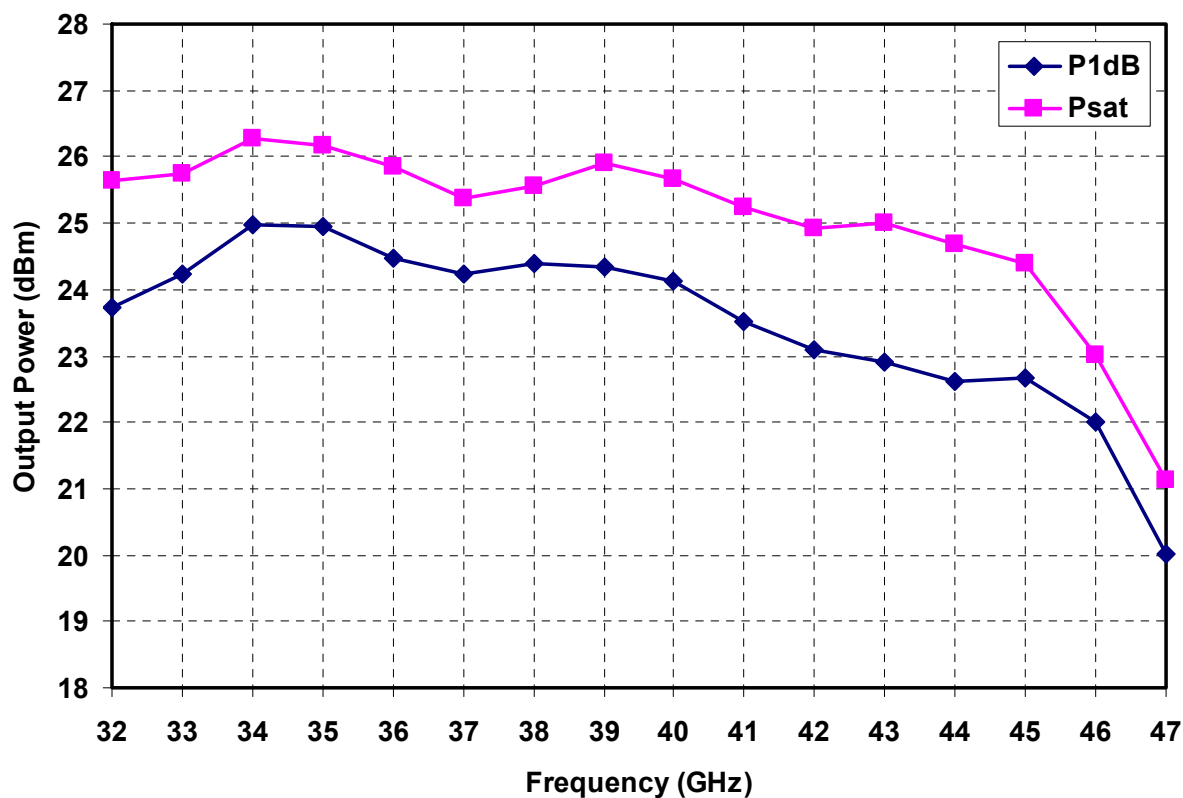
## Measured Data

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_{dq} = 175\text{ mA}$



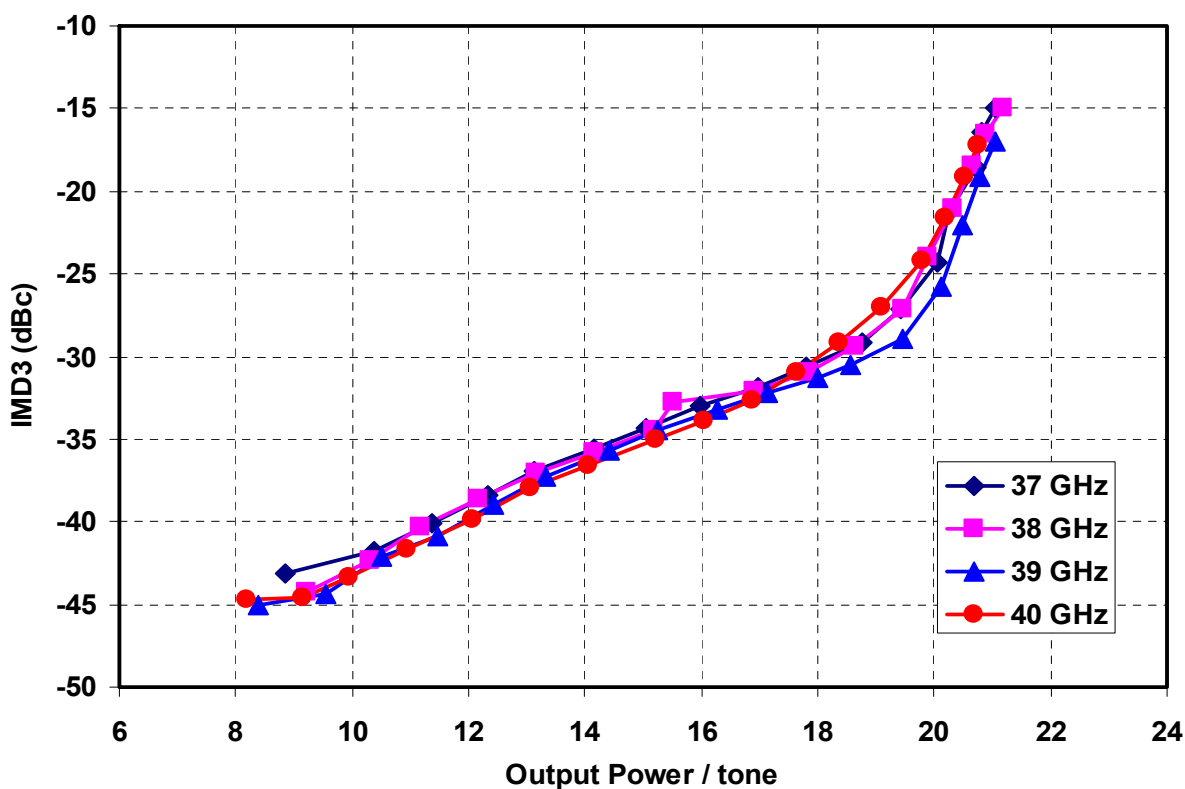
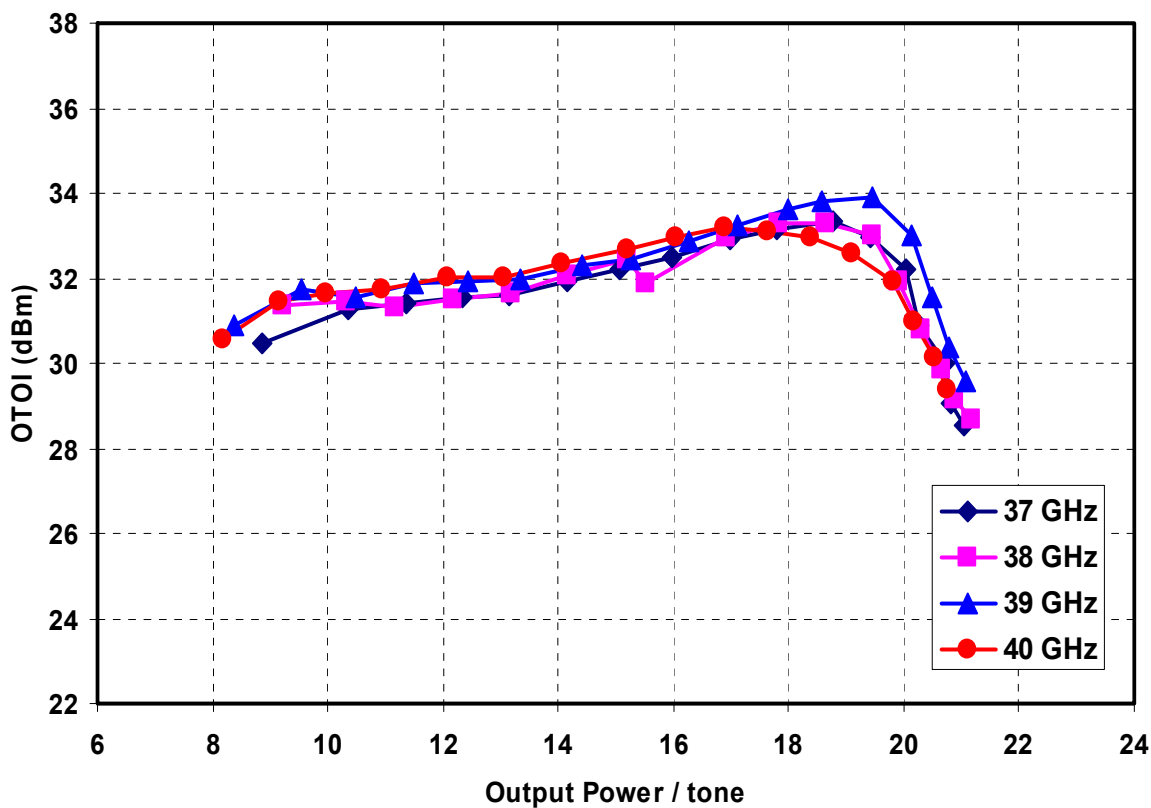
## Measured Data

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_{dq} = 175\text{ mA}$

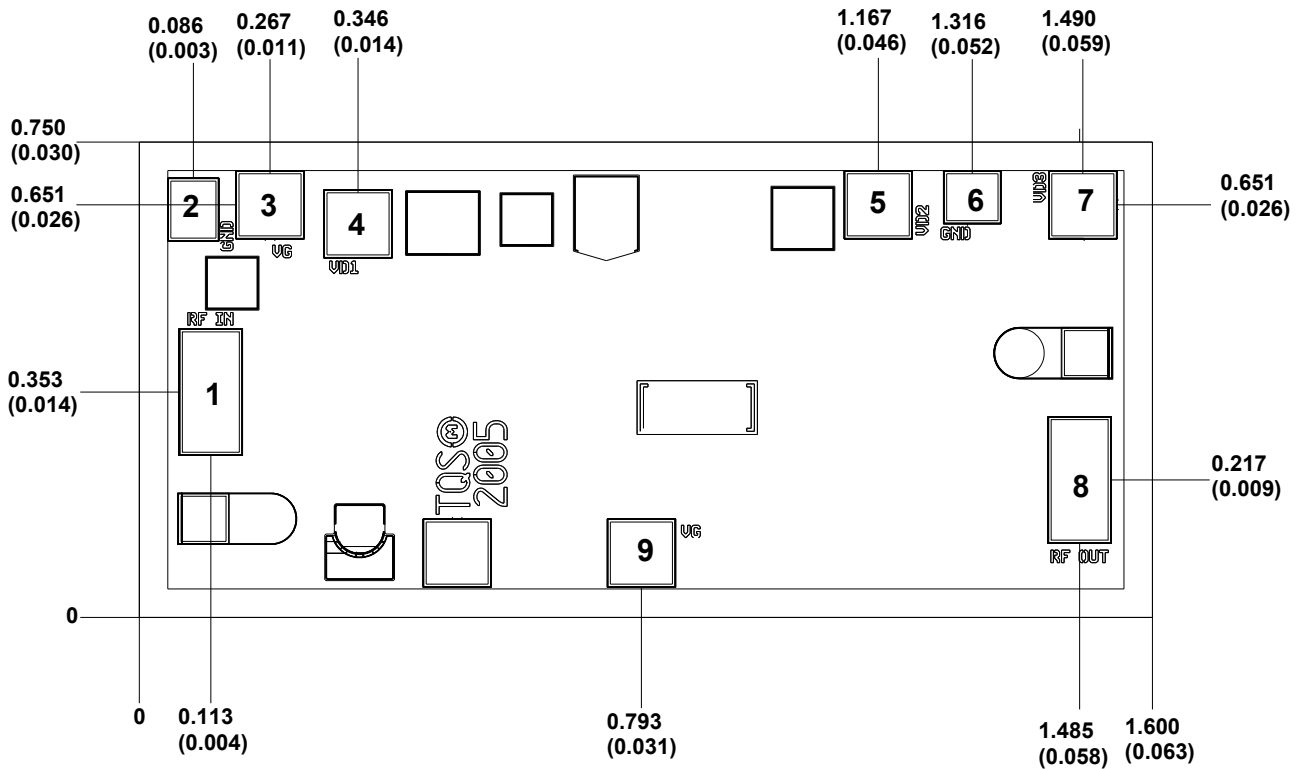


## Measured Data

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_{dq} = 175\text{ mA}$ ,  $\Delta f = 10\text{ MHz}$



## Mechanical Drawing



Units: millimeters (inches)

Thickness: 0.100 (0.004)

Chip edge to bond pad dimensions are shown to center of bond pad

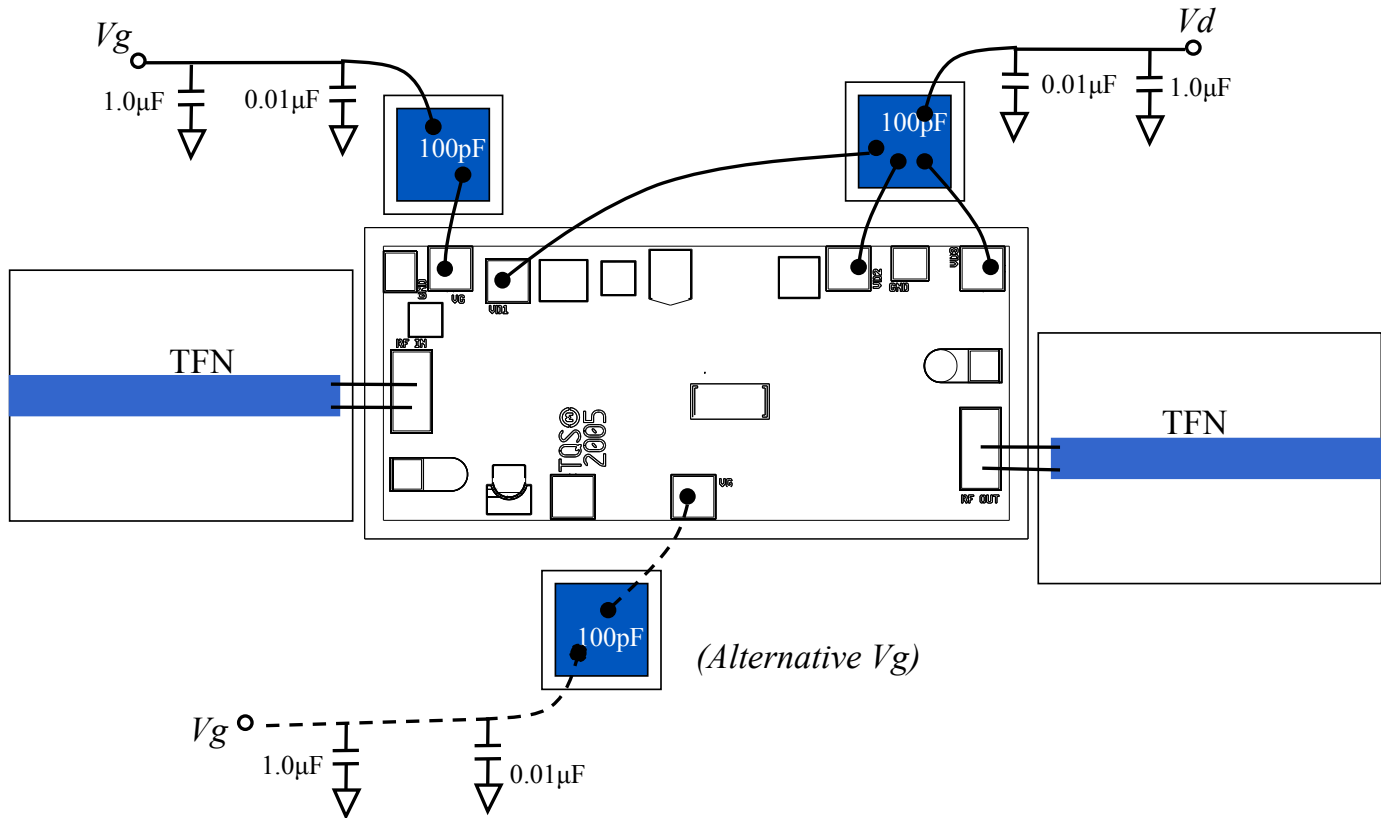
Chip size tolerance: +/- 0.051 (0.002)

GND is back side of MMIC

Bond pad #1	(RF In)	0.100 x 0.200	(0.004 x 0.008)
Bond pad #2	(N/C)	0.081 x 0.100	(0.003 x 0.004)
Bond pad #3, 9	(Vg)	0.108 x 0.108	(0.004 x 0.004)
Bond pad #4, 5, 7	(Vd)	0.108 x 0.108	(0.004 x 0.004)
Bond pad #6	(N/C)	0.091 x 0.084	(0.004 x 0.003)
Bond pad #8	(RF Out)	0.100 x 0.200	(0.004 x 0.008)

**GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.**

## Recommended Chip Assembly Diagram



**Bias Conditions:**  $V_d = 6\text{ V}$   
 $V_g = \sim -0.7\text{ V}$  to get 175mA  $I_d$

**GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.**



## Assembly Process Notes

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment (i.e. epoxy) can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.

Reflow process assembly notes:

- Use AuSn (80/20) solder and limit exposure to temperatures above 300°C to 3-4 minutes, maximum.
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- Do not use any kind of flux.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Interconnect process assembly notes:

- Ball bonding is the preferred interconnect technique, except where noted on the assembly diagram.
- Force, time, and ultrasonics are critical bonding parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.

## Ordering Information

Part	Package Style
TGA4521	GaAs MMIC Die

***GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.***